

INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Attorney Docket Number	6616-67037
	Application Number	Not yet assigned
	Filing Date	October 21, 2003
	First Named Inventor	Keller
	Art Unit	Not yet assigned
	Examiner Name	Not yet assigned

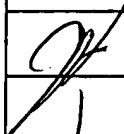
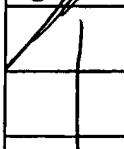
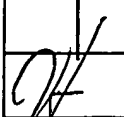
U.S. PATENT DOCUMENTS

Examiner's Initials*	Cite No. (optional)	Number	Date	Name
J/s		792,958	06/20/1905	Bagger
		2,546,838	03/27/1951	Tasche
		3,738,530	06/12/1973	Fine et al.
		3,929,234	12-1975	Warren
		3,986,638	10/19/1976	DeHart
		4,106,414	08/15/1978	Vastag
		4,228,864	10/21/1980	Berger et al.
		4,627,190	12-1986	Little
		4,998,945	03-1991	Holt et al.
		5,222,854	06-1993	Blatt et al.
		5,321,212	06/14/1994	Wadell
		5,350,269	09-1994	Azuma et al.
		5,385,441	01-1995	Swapp et al.
		5,414,955	05-1995	Morin
		5,452,981	09-1995	Crorey et al.
J/s		5,573,558	11-1996	Huang
		6,053,220	04-2000	Lo et al.

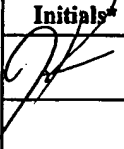
EXAMINER SIGNATURE: <i>J/s LML</i>	DATE CONSIDERED: <i>2/27/05</i>
<p>* Examiner: Initial if reference considered, whether or not in conformance with MPEP 609. Draw line through cite if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>	

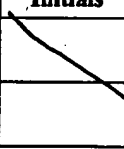
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		6,150,158	11/21/2000	Bhide et al.
		6,213,709	04-2001	Hebrank
		6,283,051	09/2001	Yoss
		6,359,454	03-2002	Khoury
		US-2002/0070150	06-2002	Keller et al.

FOREIGN PATENT DOCUMENTS

Examiner's Initials*	Cite No. (optional)	Number	Date	Country
		WO 97/20209	05 June 1997	PCT

Examiner's Initials*	Cite No. (optional)	OTHER DOCUMENTS
		

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SIGNATURE:DATE
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